Applications for a Laser-Driven Accelerator on a Chip

R. J. England (SLAC, Stanford)

SPIE Optics and Optoelectronics, Workshop on Applications of Laser-Driven Particle Accelerators (ALPA) April 2-3, Prague, Czech Republic





In what ways could smaller more affordable particle accelerators benefit us?

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X-rays

phase contrast imaging



The later of the set o

Etched

Accelerator Structures

Channel

Electron

Source



Fig. 3 Dark field optical microscope on review SEM.

Wafer

DFOM : Dark Field Optical Microscope

Particle

industrial wafer inspection

portable cancer treatment

university-scale x-ray laser

Fiber Couplers

Undulator

R. L. Byer, Stanford

SiO₂ wafer

Dielectric Laser Acceleration (DLA) Concept



laser-driven microstructures

- <u>lasers:</u> high rep rates, strong field gradients, commercial support
- <u>dielectrics</u>: higher breakdown threshold → higher gradients (1-10 GV/m), leverage industrial fabrication processes

"Accelerator-on-a-chip"



bonded silica phase reset accelerator prototypes fabricated at SLAC/Stanfo rd

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Goal: lower cost, more compact, energy efficient, higher gradient

Wafer is diced into individual samples for e-beam tests.





DLA leverages advances in two major industries: solid state lasers + semiconductor fabrication

Not high peak power lasers!

Parameter	DLA Value
Wavelength	2 µm
Pulse Duration	100 fs
Pulse Energy	1 µJ
Laser Power	100 W
Rep Rate	100 MHz
Laser Efficiency	30%
Cost/laser	\$150k



Available now "off the shelf"

Fabricated using techniques of the integrated circuit industy.



DLA structures are made by students in the Nanofabrication Facilities at partner universities.

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SEM images of DLA prototypes tested at NLCTA



fused silica



silicon

A 5-Year initiative in DLA has been funded by the Gordon and Betty Moore Foundation (2015 – 2020)



ACHIP Scientific Advisory Board:

Chan Joshi (UCLA), Tor Raubenheimer (SLAC), Reinhard Brinkmann (DESY)

What has been done to date?

compact field emission e- sources





Hoffrogge, et al. J. Appl. Phys. 115, 094506 (2014)

high gradient ($0.3 \rightarrow 0.85 \text{ GV/m}$)



Leedle, et al. Opt. Lett. 40, 4344 (2015)



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Cesar et al., Nat. Comm. Phys. (2018)



"staging" with 2 lasers sub-relativistic focusing



beam position monitor



Opt. Lett., 37 (5) 975-977 (2012) Opt. Lett., 39 (16) 4747 (2014)

J. McNeur, "Elements of a Dielectric Laser Accelerator," Optica 5 (6), 687 (2018)

High Brightness Photocathodes Tested Under the ACHIP Program...

		340nm	FIM FIM Ban- La*		
	W tip (Erlangen)	W tip w/ diamond (Erlangen)	LaB ₆ nanowire (Erlangen)	diamond pyramid (Los Alamos)	Si nanotip
R (nm)	(<1.0)	170	(1.5)	<10	15
max e ⁻ /pulse	625	1000	20	12000	1000
ϵ_n (nm)	0.1	0.35	0.1	?	0.25
$B_{5D,n}$ (A/cm ²)	6.7e12	1e10	1.1e12	?	1e12
stability	30 min	>1 hour	?	>1 hour	>1 hour
integrated	Ν	Ν	Ν	Y	Y

A. Ceballos, DLA Applications Workshop, March 26 (2019)

Structures Incorporating Laser-Driven Focusing Have Been Recently Fabricated for Experimental Tests



Hommelhoff Group, FAU Erlangen, Germany

Niedermayer, et al., PRL **121**, 214801 (2018)

- First APF structure optimized for 2000 nm laser wave length and 26.478 keV electron beam Structure length required pulse front tilted (PFT) laser pulses
- Structure is only for guiding as a proof-of-principle
- Goal is to see a maximum laser ON/OFF contrast of 2.5:1
- Additionally the contrast should scale with incident laser power

Phase manipulation provides a means of transverse focusing using the laser field itself

Alternate between transverse focusing-longitudinal defocusing and transverse defocusing-longitudinal focusing \rightarrow net focusing



83 keV → >1 MeV:
56% transmission for 100pm emittance,
93% for 25pm emittance

U. Niedermayer, T. Egenolf, O. Boine-Frankenheim, P. Hommelhoff, Phys. Rev. Lett. 121, 214801 (2018)

Concept for 1 MeV "Shoebox" Accelerator (1 Year)

A single bunching/acceleration/focusing stage driven by a tilted laser pulse.



A compact prototype "shoebox" test system is now operating at Stanford University – goal of 1 MeV energy

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55 keV e- gun; nA beam current Silicon tip emission source; Hexapod positioning stage

image courtesy K. Leedle, J. Harris lab (Stanford University)

Multistage Waveguide Network Design for a Dielectric Laser accelerator





couplers





splitters



phase shifters

T. Hughes, et al. "On-Chip Laser Power Delivery System for Dielectric Laser Accelerators," Phys. Rev. Appl. 9, 054017 (2018)

- Design Study of Integrated Multi-Stage DLA Network
- Realistic Component Parameters
- Adjoint Variable ("Inverse Design") Based Structure Optimizations

Direct Coupling to a Waveguide Network with MZI Control Removes Bottlneck at the Input Facet

splitting structure

Hughes, et al. PRA 9, 054017 (2018)



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Hughes, England, Fan, submitted, PRA (2019)



Concept for Injector + Multistage Accelerator (2-5 Year)



A 1-Day workshop was held last week at Stanford University to explore potential Applications



2nd workshop on Applications of Dielectric Laser Accelerators

26 March 2019 Stanford University US/Pacific timezone

Overview

Timetable

Contribution List

Registration

Modify my Registration

Participant List

Workshop Dinner

Workshop Location

We are pleased to announce a one-day by-invitation-only meeting to be hosted on March 26, 2019 at Stanford University. The goal of this meeting is to explore applications for a future compact dielectric micro-structure based accelerator powered by ultrafast solid state lasers. This approach to particle acceleration, colloquially referred to as an "accelerator on a chip", has garnered increasing interest in recent years.

The Accelerator on a Chip International Program (ACHIP), a multi-institutional research program led by Stanford University and Friedrich-Alexander-University Erlangen-Nuremberg (FAU), and funded by the Gordon and Betty Moore Foundation, has been formed to address the many scientific and engineering challenges of advancing this technology toward useful applications. As part of this program, we have established a working group to explore Radiation Generation and Applications for dielectric laser-driven accelerators.

Applications Identified by the March 2019 DLA Applications 1-Day Workshop

potential areas of industry interest

- Biomedicine industry
 -- Radiation therapy
- Semiconductor industry
 -- low-power EUV for mask/wafer inspection/calibration

potential areas of scientific interest

- Nano- or micro-beam for radiobiology and radiation chemistry
- Ultrafast electron diffraction, X-ray pulses at sub-fs time scales





A Small Footprint Medical Accelerator Directly Maps to DLA's Unique Features

Parameter	Desired Capability	Unique DLA Features
Electron energy	10-20 MeV	Single-wafer design with 1 GV/m gradient
Useful dose	1 Gray/sec	2000 e- per bunch; 2 MHz rep rate
Treatment Volume	5-10 cm ³	Directed (vs omnidirectional) beam and on- chip deflection to scan tumor area
Small footprint	~ 1 cm x 10 cm	2um wavelength optical scale device with 2 cm active linac length
Wall Plug Power	< 100 Watt	Modest 2.9% wall-plug to electron efficiency





High-Brightness DLA Beams for Ultrafast Electron Diffraction – Renkai Li (SLAC, Tsing Hua U., Beijing)



Typical UED beam parameters

Parameters	Values
rep. rate	SS - 180 Hz
beam energy	2 - 4 MeV
bunch charge	10 ⁴ -10 ⁶
emittance	2 - 20 nm
bunch length	<50 fs rms

- e- probes can tackle broad range of scientific puzzles
- Imaging and energy loss spectroscopy more challenging, which require energy spread and stability
- DLAs based UED will be compact, all optical control
- Lower emittance, potentially reduced time-of-arrival jitter
- Promising sources for UED with improved probe size, q-resolution, and temporal resolution

Characteristics of Interest for Industrial Applications

Parameter	Desired specifications
Wavelength	UV to X-ray, broad or narrow band
Brilliance	> 10 ¹⁰ photon/(sec mm2 mrad2 0.1%BW)
Brightness	> 10 ⁸ -10 ¹² photons/(sec sr)
Pulse width	< Sub femto second for High speed image < 1ns for inspection
Repetition rate	> 1-100 MHz
Unit cost	Depends on application

- Inspection for semiconductor wafer, mask
- Spectroscopy
- Imaging

slide courtesy T. Hirano, Hamamatsu



EUV Source for Wafer Inspection



J. Vac. Soc. Japan 10, 578 (2010)

Rayleigh scattering intensity, $I = k I_0 d^6 / \lambda^4$ k = constant, I_0 = incident light intensity d = particle diameter, λ = wavelength

Higher power and shorter wavelength are better

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What about the possibility of a DLA based light source?

Large facilities are often oversubscribed (e.g. the Linac Coherent Light Source at SLAC has ~ 5 times more proposals than it can accommodate)

Compact footprint and reduced cost would give university labs and smaller facilities greater access (e.g. an FEL in every university)

Sub-optical wavelength (attosecond) temporal bunch structure if translated into sub-fs radiation pulses would be useful for ultrafast science (molecular movies, atomic physics).

Compact, **portable scanners** for security (Nuclear Fluorescence), phase contrast imaging and medicine.

Components of a DLA Light Source

Overall goal: The demonstration of an integrated multi-stage particle "accelerator on a chip" will validate the potential to scale to energy levels of interest for "real-world" applications.

- 1. On-chip electron source
- 2. DLA structure development: (a) subrelativistic, (b) relativistic
- 3. Multi-staged acceleration
- 4. Coupling of laser to DLA
- 5. Laser-driven undulator



Concept for a compact laser-driven undulator for EUV production





An equal superposition of the TE and TM fundamental modes produces a pure deflection mode (i.e. no E_z component)!

A. Ody, R. J. England, Z. Huang, Advanced Accelerator Concepts Workshop 2018

DLA's attosecond bunch structure raises the possibility of making attosecond radiation pulses

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Optical structures naturally have sub-fs time scales and favor high repetition rate operation



EUV Attosecond Frequency Comb

Modelocking scheme proposed could enable attosecond radiation pulses (R. J. England, Z. Huang, FLS 2018)



Parameter	Unit	Value
Beam Energy	MeV	40
Microbunch Charge	fC	10
Undulator Period	μm	250
Number of periods / Delay Modules	#	10 / 100
EUV Photon Energy	eV	50
Radiated Pulse Energy	nJ	100

DLA X-ray FEL Strawman Parameter Table



Parameter	Units	Value
Ebeam Energy	GeV	1.056
Microbunch Charge	fC	0.5
Bunches per Train		150
Rep Rate	MHz	100
Normalized Emittance	nm	0.87
Laser Wavelength	μm	2
Laser Pulse Duration	ps	1
Undulator Period	mm	0.9
Equivalent Undulator B	Т	1.6
Undulator K		0.14
Pierce Parameter		2.29E-04
Undulator Length	m	0.9
Photon Energy	keV	11.5
Gain Length	m	0.18
Photons per Bunch		6.6E+04
Photon Flux	photons/sec	9.9E+14
Brightness	SBU*	1.05E+21

A DLA X-ray source would be in or near the Quantum FEL regime:

$$\frac{\hbar\omega}{\gamma\,m\,c^2} = 10^{-5}$$

* 1 "SBU" = ph/s/mm²/mrad²/0.1%BW

A miniaturized attosecond XFEL could enable revolutionary new science capabilities.



Concept for multi-axis ultrafast tomography with DLA based XFELs (K. Wootton)

What about protons or ions?



Reduce size/cost for <u>colliding beam</u> <u>fusion reactor (CBFR)</u>.

Possible uses for plasma diagnostic measurements of ion temperature, plasma density with lower beam powers.



Desired Delivery Parameters (c/o: Dr. M. Thompson, Tri-Alpha)

Parameter	Value
Proton Energy	15 keV to 1 MeV
Beam power	1 MW
Beam Brightness	low / unimportant

Preliminary Estimated Source Requirements

Parameter	Value
Proton Energy	> 10 MeV desired
Size	Compact (< 1 meter)
Emittance	<< 1 µm
Beam format	Pulsed, laser synced, high rep rate (MHz)

- In principle DLA can accelerate any charged particle.
- Existing tabletop p+ sources not suitable for a final device, but may be useful for demonstration tests; feasibility studies needed.
- Demonstration experiments would be interesting with suitable test facilities.

What are DLA's Unique Capabilities?



"Create a matrixed list or table of all DLA related applications that have been proposed or discussed so far, both near and long-term, including industrial, scientific, and medical. Please evaluate each application in terms of area of interest (light source, HEP, industry, medicine, security, etc.), feasibility (is DLA a good match?), time scale (near-term vs. long-term), and **degree to which it leverages DLA's unique capabilities**."



Features of a DLA Accelerator:

- <u>C</u>ompactness: x10⁻² longitudinal, x10⁻⁴ transverse
- <u>Efficiency</u>: solid state lasers (> 30% wall-plug)
- <u>B</u>unch Format: fC charge at MHz rep rates
- <u>A</u>ttosecond Time Scale: intrinsic optical bunching
- <u>U</u>niquely enabled by DLA?

DLA Applications Matrix



Application	Field	Time-Scale	Compactness	Efficiency	Brightness	Attosecond	Unique to DLA?
Compton X-ray Source	Medical	Mid	٧				
Catheterized Electron Source	Medical	Mid	V				٧
Proton/Hadron Therapy	Medical	Long	V				
Linear Collider	HEP	Long	٧	V	٧		
Low-power EUV for inspection	Industry	Mid	V				
Colliding Beam Fusion	Industry	Long	V	\mathbf{v}			
Micro-beams for radiobiology	Science	Near	V				
UED/UEM Source	Science	Near	\checkmark		V	\checkmark	
Compact XFEL	Science	Long	V	\checkmark	V	V	
Multi-Axis Tomography	Science	Long	\checkmark	\mathbf{v}	\mathbf{v}	\checkmark	٧

Conclusions



Significant progress in DLA over the last few years:

Ongoing 5-year international collaboration funded by Moore Foundation Gradients ~ 1 GV/m, energy gain > 0.3 MeV recently demonstrated Components for an integrated on-chip system in development Prototype "shoebox" demonstration system ready for testing

Key Strengths of DLA

short-bunch superradiance, diffraction-limited radiation (high brightness) nm spatial and temporal resolution energy efficient for applications (precise beam pointing) reduced size and cost

Prospects for DLA-based Applications

medical radiation oncology (direct ebeam treatment) industrial EUV sources for low-power wafer inspection attosecond science, electron diffraction, microscopy

New ideas are welcome!

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blue = students; * = current Bob Siemann fellows

Thank you!





Group photo, ACHIP collaboration meeting at DESY, Hamburg, Germany, Sept 19-21, 2018.

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